AMENDMENTS TO THE CLAIMS

1. **(Currently amended)** A method for electrolytic coating of ~~materials~~ a material with aluminum, magnesium or alloys of aluminum and magnesium, ~~in which~~ said method comprising

~~the material is immersed~~ immersing the material in an electrolytic bath comprising electrolyte for pretreatment, wherein said material ~~being~~ is connected as anode therein, and

performing electrolytic coating ~~is performed~~ in the same electrolyte immediately thereafter, the electrolytic bath ~~including~~ comprising organoaluminum compounds of general formulas (I) and (II)

$$M[(R^1)_3Al\text{-}(H\text{-}Al(R^2)_2)_n\text{-}R^3] \qquad (I)$$

$$Al(R^4)_3 \qquad (II)$$

as electrolyte, wherein n is equal to 0 or 1, M is sodium or potassium, and R^1, R^2, R^3, R^4 can be the same or different, R^1, R^2, R^3, R^4 being a C_1-C_4 alkyl group, and a halogen-free, aprotic solvent being used as solvent for the electrolyte.

2. **(Currently amended)** The method according to claim 1, ~~characterized in that~~ wherein a mixture of the complexes $K[AlEt_4]$, $Na[AlEt_4]$ and $AlEt_3$ is employed as electrolyte. .

3. **(Currently amended)** The method according to claim 2, ~~characterized in that~~ wherein ~~the~~ a molar ratio of said complexes $K[AlEt_4]$, $Na[AlEt_4]$ to $AlEt_3$ is from 1:0.5 to 1:3~~, preferably 1:2~~.

4. **(Currently amended)** The method according to claim 2 ~~or 3~~, ~~characterized in that~~ wherein 0 to 25 mole-%~~, preferably 5 to 20 mole %~~ $Na[AlEt_4]$ is employed, relative to the mixture of the complexes $K[AlEt_4]$ and $Na[AlEt_4]$.

5. **(Currently amended)** The method according to Claim 2 ~~one or more of claims 1 to 4~~, ~~characterized in that~~ wherein a mixture of 0.8 mol $K[AlEt_4]$, 0.2 mol $Na[AlEt_4]$, 2.0 mol $AlEt_3$ in 3.3 mol toluene is used as electrolyte.

6. **(Currently amended)** The method according to claim 1, ~~characterized in that~~ wherein a mixture of $Na[Et_3Al\text{-}H\text{-}AlEt_3]$ and $Na[AlEt_4]$ and $AlEt_3$ is used as electrolyte.

7. **(Currently amended)** The method according to claim 6, ~~characterized in that~~ wherein ~~the~~ a molar ratio of $Na[Et_3Al\text{-}H\text{-}AlEt_3]$ to $Na[AlEt_4]$ is from 4:1 to 1:1~~, preferably 2:1~~.

8. **(Currently amended)** The method according to claim 7, ~~characterized in that~~ wherein ~~the~~ a molar ratio of $Na[AlEt_4]$ to $AlEt_3$ is 1:2.

9. **(Currently amended)** The method according to ~~one or more of claims 6 to~~ Claim 8, ~~characterized in that~~ wherein a mixture of 1 mol $Na[Et_3Al\text{-}H\text{-}AlEt_3]$, 0.5 mol $Na[AlEt_4]$ and 1 mol $AlEt_3$ in 3 mol toluene is used as electrolyte.

10. **(Currently amended)** The method according to ~~one or more of claims~~ Claim 1 ~~to~~ ~~9~~, ~~characterized in that~~ wherein electrolytic coating is ~~effected~~ performed at temperatures of from 80 to 105°C~~, preferably from 91 to 100°C~~.

11. **(Currently amended)** The method according to ~~one or more of claims~~ Claim 1 ~~to~~ ~~10~~, ~~characterized in that~~ wherein pretreatment is performed for a period of from 1 to 20 minutes~~, preferably from 5 to 15 minutes~~.

12. **(Currently amended)** The method according to ~~one or more of claims~~ Claim 1 ~~to~~ ~~11~~, ~~characterized in that~~ wherein pretreatment is performed at an anodic load of the ~~materials~~ material with a current density of from 0.2 to 2 A/dm^2~~, preferably from 0.5 to 1.5 A/dm^2~~.

13. **(New)** The method of Claim 3, wherein the molar ratio of said complexes $K[AlEt_4]$, $Na[AlEt_4]$ to $AlEt_3$ is 1:2.

14. **(New)** The method according to claim 4 wherein 5 to 20 mole-% $Na[AlEt_4]$ is employed, relative to the mixture of the complexes $K[AlEt_4]$ and $Na[AlEt_4]$.

15. **(New)** The method of Claim 7, wherein the molar ratio of $Na[Et_3Al\text{-}H\text{-}AlEt_3]$ to $Na[AlEt_4]$ is 2:1.

16. **(New)** The method of Claim 10, wherein electrolytic coating is performed at temperatures of from 91 to 100°C.

17. **(New)** The method of Claim 11, wherein pretreatment is performed for a period of from 5 to 15 minutes.

18. **(New)** The method of Claim 12, wherein pretreatment is performed at an anodic load of the material with a current density of from 0.5 to 1.5 A/dm^2.